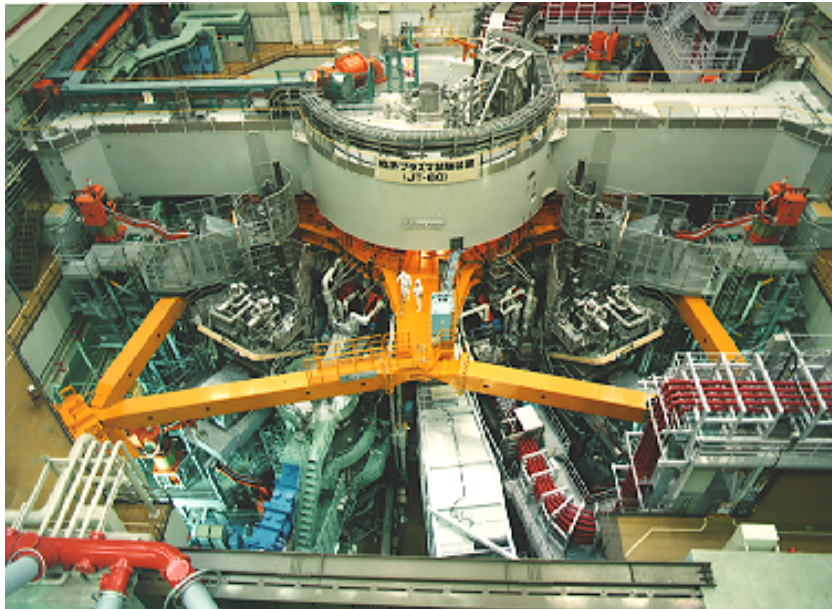


Transport study in reactor-relevant regime on JT-60U towards advanced steady-state tokamak operation



**H. Takenaga and
the JT-60 Team**

**Japan Atomic Energy
Research Institute**

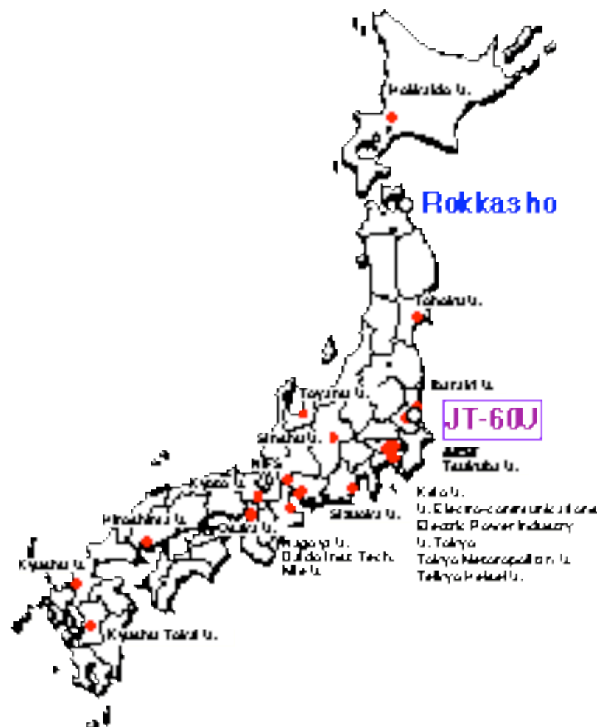
**30th EPS Conference on Controlled
Fusion and Plasma Physics
St Petersburg, Russia, July 7-11 2003**

Enhanced collaboration with domestic and foreign universities/laboratories

JT-60U

- Many collaborators from domestic and foreign universities and laboratories contribute to the JT-60 program.

In JAPAN



From abroad

ASIPP(China), Ecole Polytech. (Switzerland), EFDA-JET (EU), GA (USA), Ioffe Inst. (RF), KBSI(Korea), KFA Juelich (Germany), Kurchatov Inst. (RF), LANL (USA), MPI-Garching (Germany), MIT (USA), ORNL (USA), PPPL (USA), SWIP (China), TRINITI(RF), U. Stractclyde (UK)



Introduction

JT-60U

- ITER Physics R&D
- Advanced Tokamak Concepts for ITER & DEMO
 - **High integrated performance;**
 - high values of β_N , HH_{y2} , f_{BS} , f_{CD} , n/n_{GW} , fuel purity, P_{rad}/P_{abs}

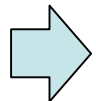
High β_p mode plasma
(weak positive shear)
Reversed shear plasma) with **internal transport barrier (ITB)**

- **Dominant electron heating ($T_e > T_i$) and small central fueling;**
 - T_e ITB formation
 - Heat and particle (including impurity) transport
 - Sustainment/degradation of ITB and confinement ?
 - Heavy impurity accumulation ?

Development of ECRF (110 GHz) and N-NB systems

ECRF : 3 MW for 2.7 s (4 units of gyrotron)

N-NB : 6.2 MW for 1.7 s (381 keV)



Extension of research area towards reactor-relevant regime

OUTLINE

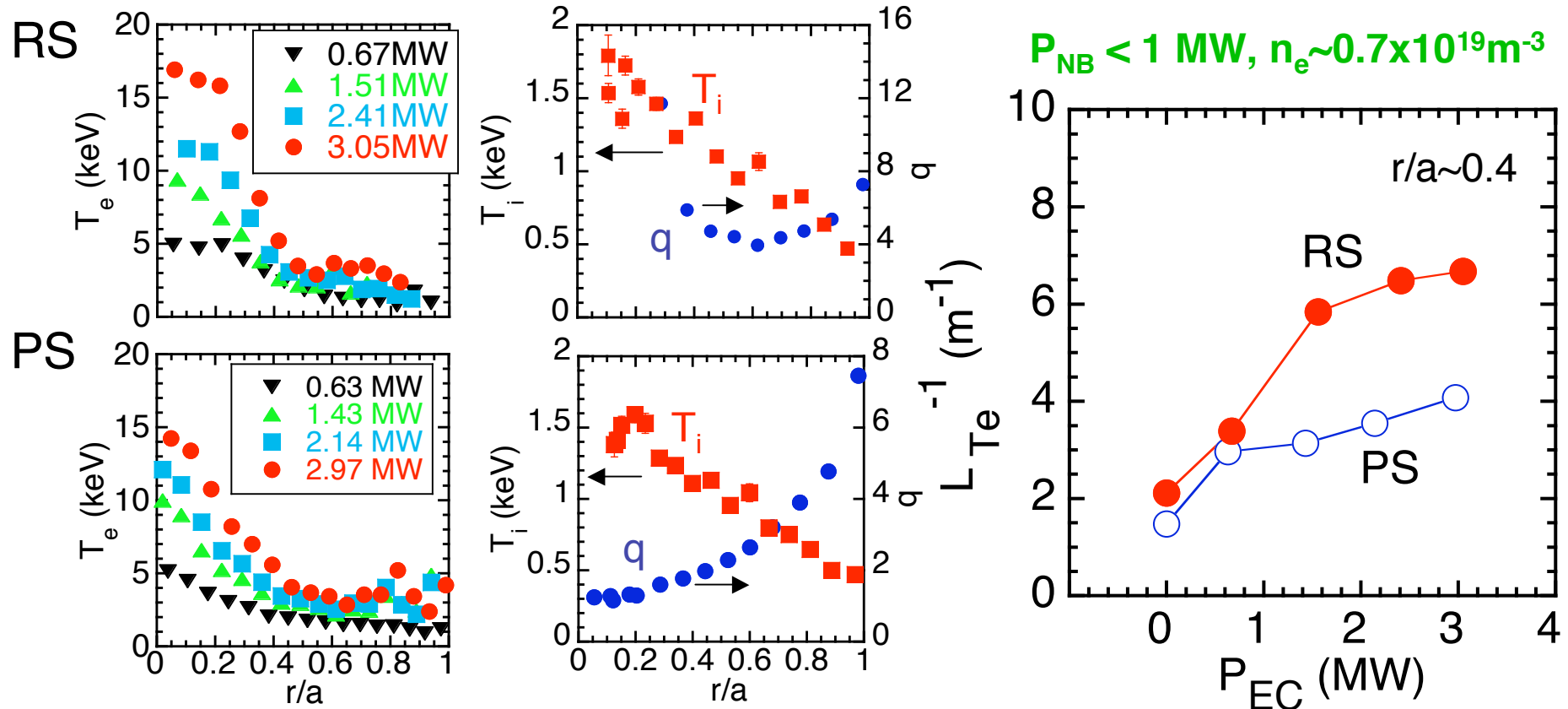
JT-60U

- T_e ITB formation condition under dominant electron heating by ECRF
- Heat and particle transport in the ITB region under dominant electron heating / small central fueling by ECRF
 - Reversed shear plasma
 - Weak positive shear plasma
- Summary and Future plan

Strong T_e ITB is formed without T_i ITB in RS plasma.

JT-60U

- T_e ITB is important to improve confinement in ITER/DEMO, where T_e is expected to be higher than T_i .
- With no/low P-NB power, **strong T_e ITB is formed in RS plasma** ($P_{EC} \sim 1$ MW) but **not formed in PS plasma** (P_{EC} up to 3 MW).

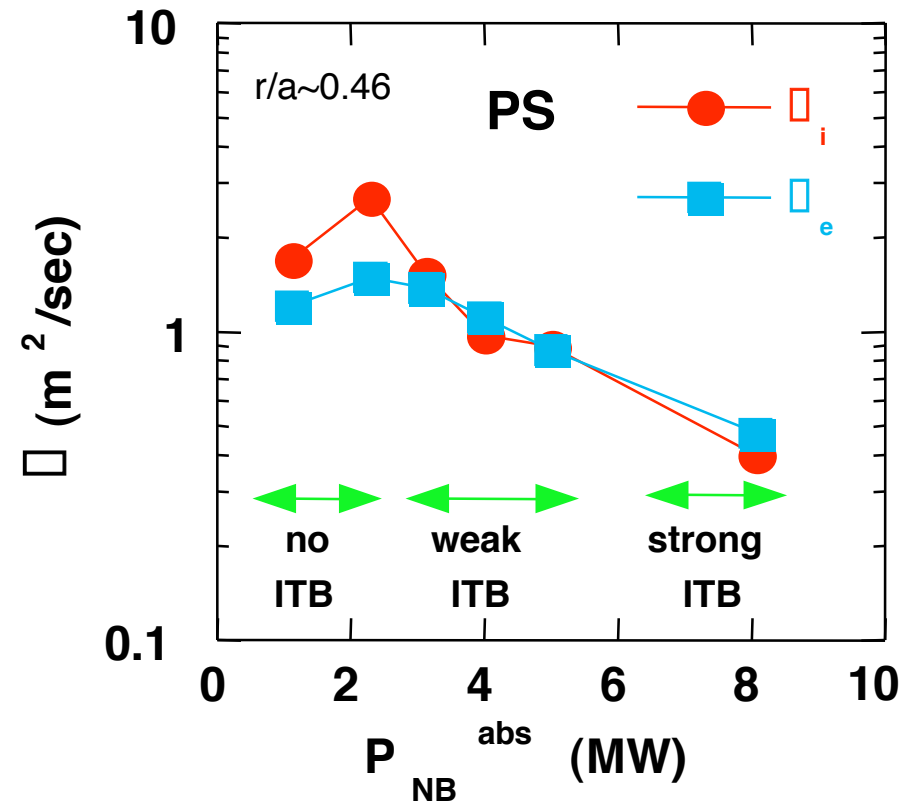
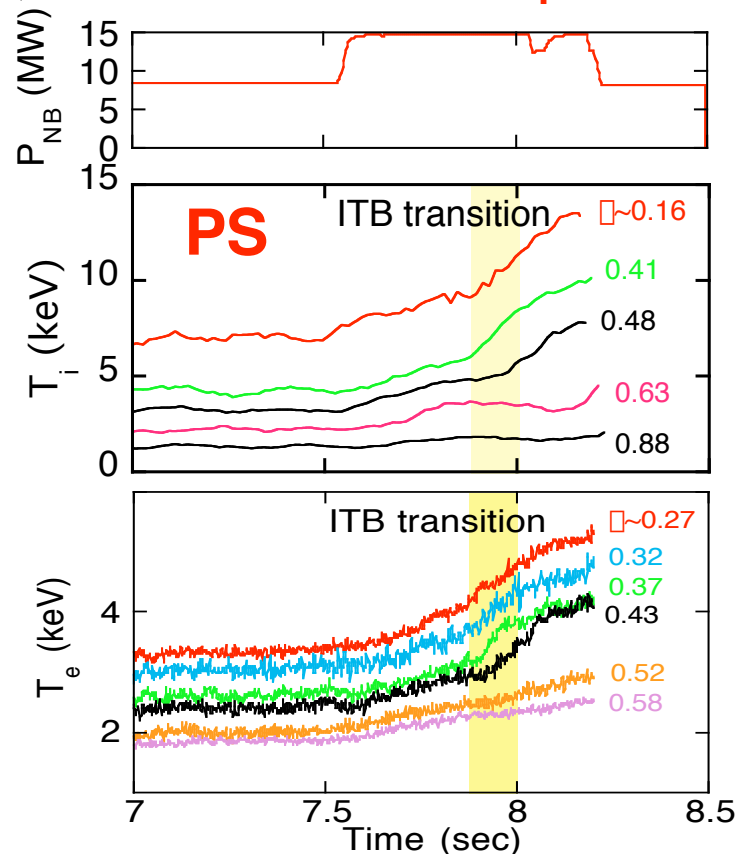


Strong T_e ITB is formed with T_i ITB in PS plasma.

JT-60U

- Formation of strong T_e ITB requires strong T_i ITB in PS plasma with high power P-NB heating.
- Electron heat transport strongly correlates with ion heat transport.

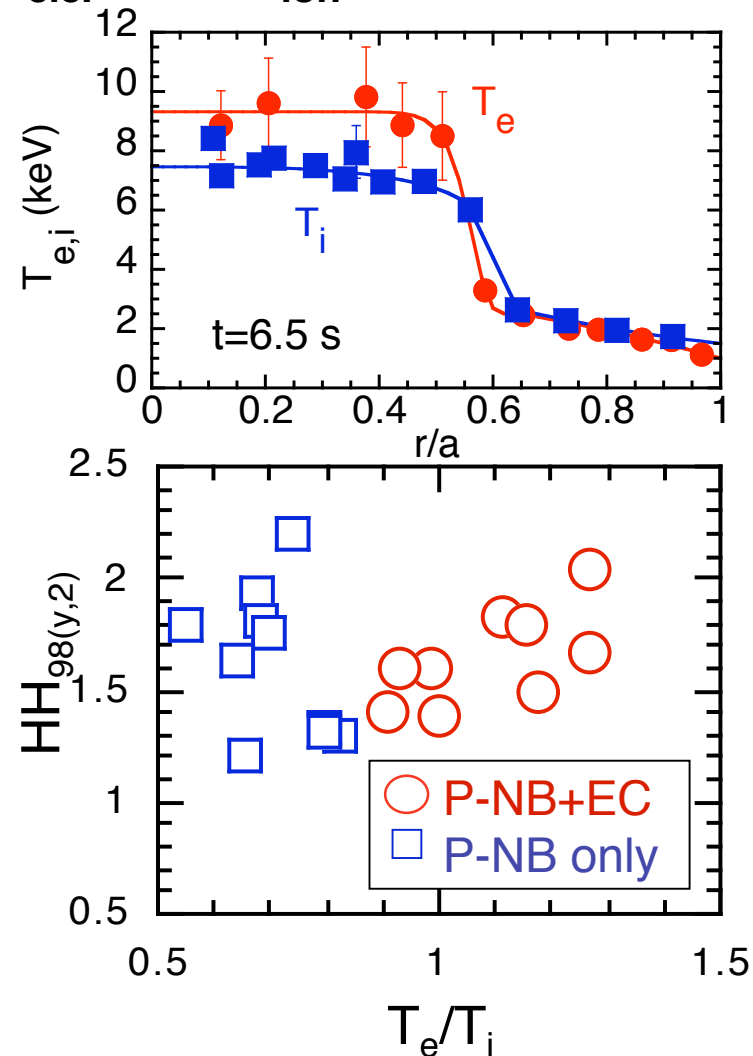
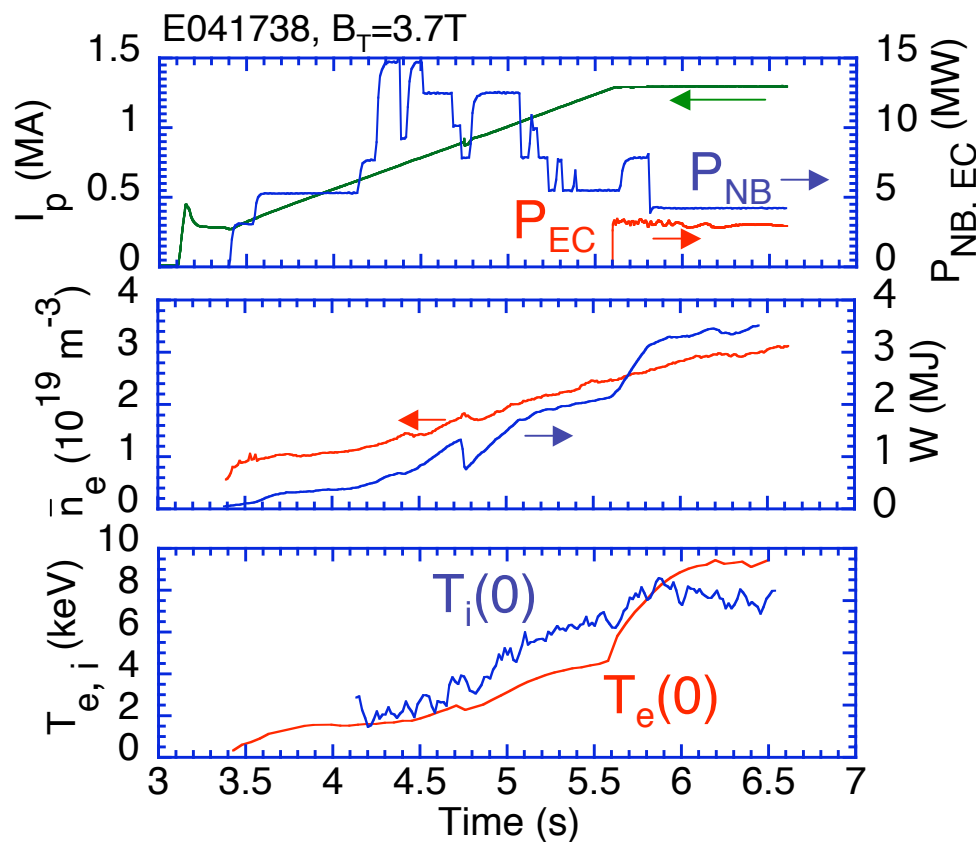
➔ Sustainment of T_i ITB under electron heating is important.



High confinement is obtained with $T_e > T_i$ in RS plasma.

JT-60U

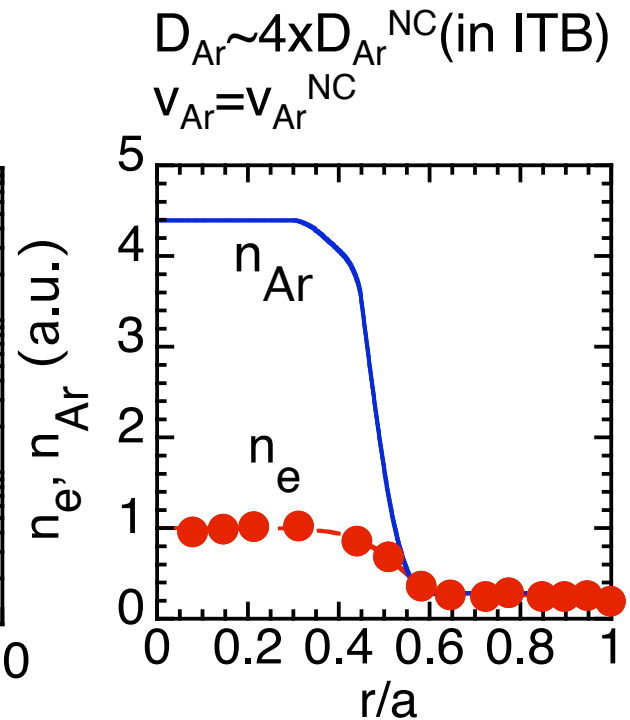
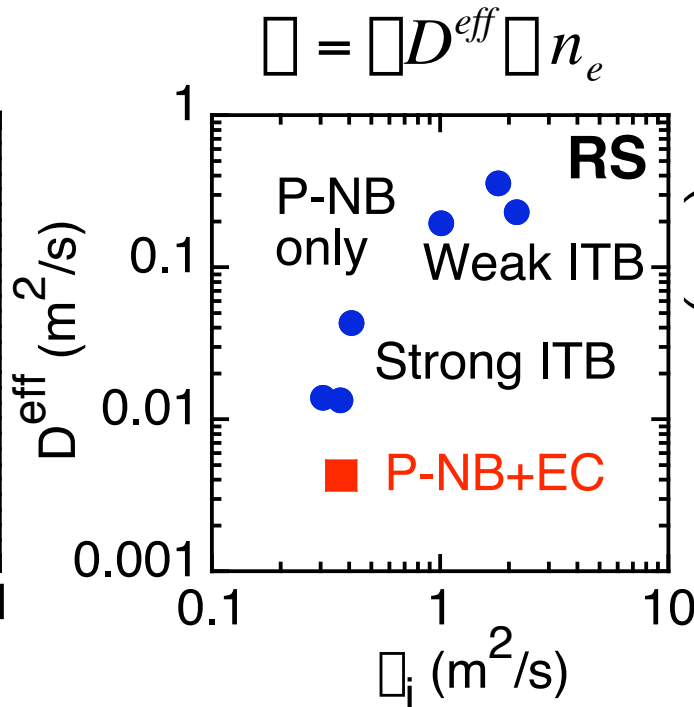
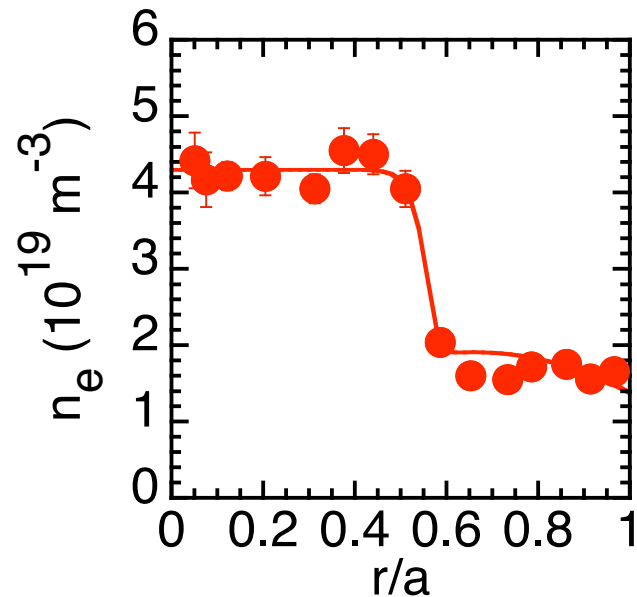
- In RS plasma, strong T_i and T_e ITBs are maintained under dominant electron heating ($P_{\text{ele.}} \sim 1.6 P_{\text{ion.}}$).
- $HH_{y2} \sim 2$ is achieved with $T_e > T_i$.



Strong n_e ITB is kept and Ar is accumulated even with small central fuelling in RS plasma

JT-60U

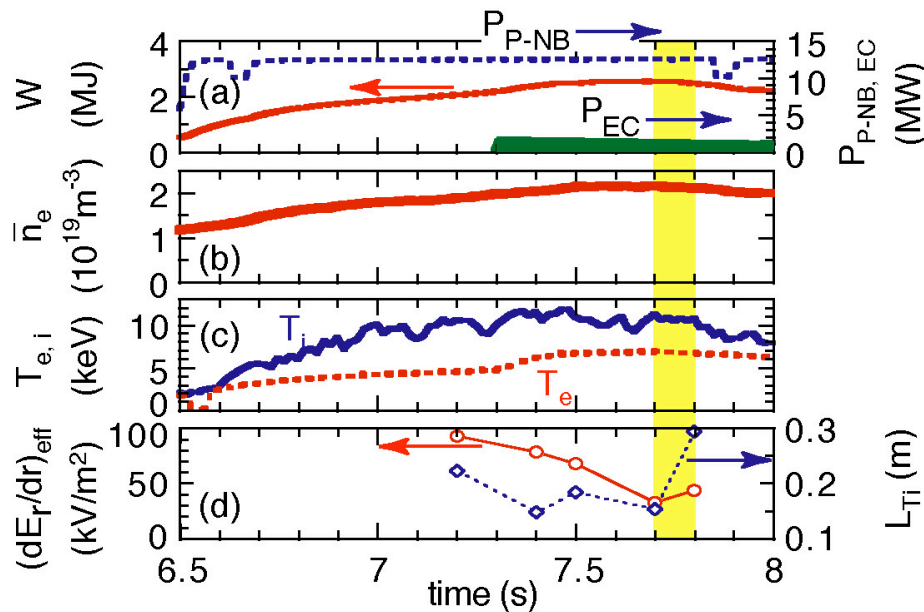
- A flat density profile is favorable for suppression of impurity accumulation due to small neoclassical inward pinch velocity.
- In RS plasma, strong n_e ITB is maintained even with small central fuelling and D^{eff} is smaller with small central fuelling.
- Ar is accumulated inside the ITB even with small central fuelling, although Ar accumulation is weaker than neoclassical prediction.



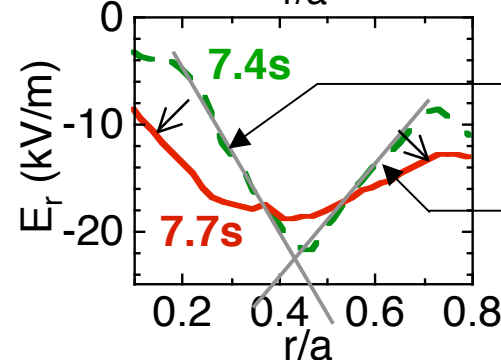
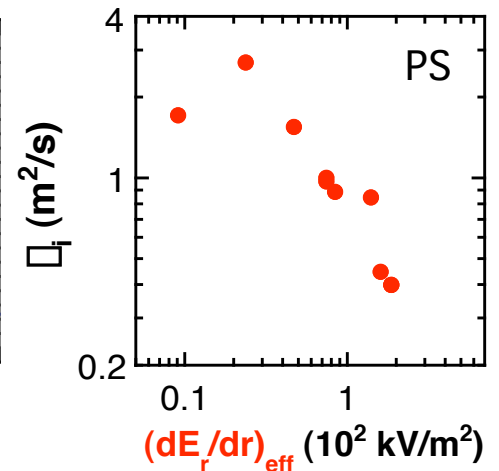
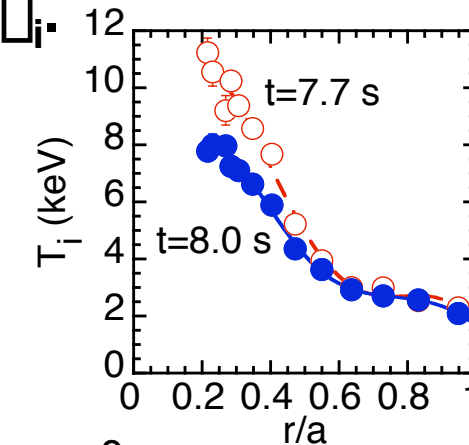
T_i ITB degrades by injecting ECRF in PS plasma

JT-60U

- Toroidal rotation is flattened and decrease of E_r shear followed by degradation of T_i ITB is observed.
- Remarkable correlation between effective E_r shear and $\bar{\omega}_i$ is observed.
- The T_i ITB degradation is consistent with the correlation between effective E_r shear and $\bar{\omega}_i$.



$$\left| \frac{dE_r}{dr} \right|_{\text{eff}} = \left| \frac{dE_r}{dr} \right|_{\text{max}} + \left| \frac{dE_r}{dr} \right|_{\text{min}} \sqrt{2}$$

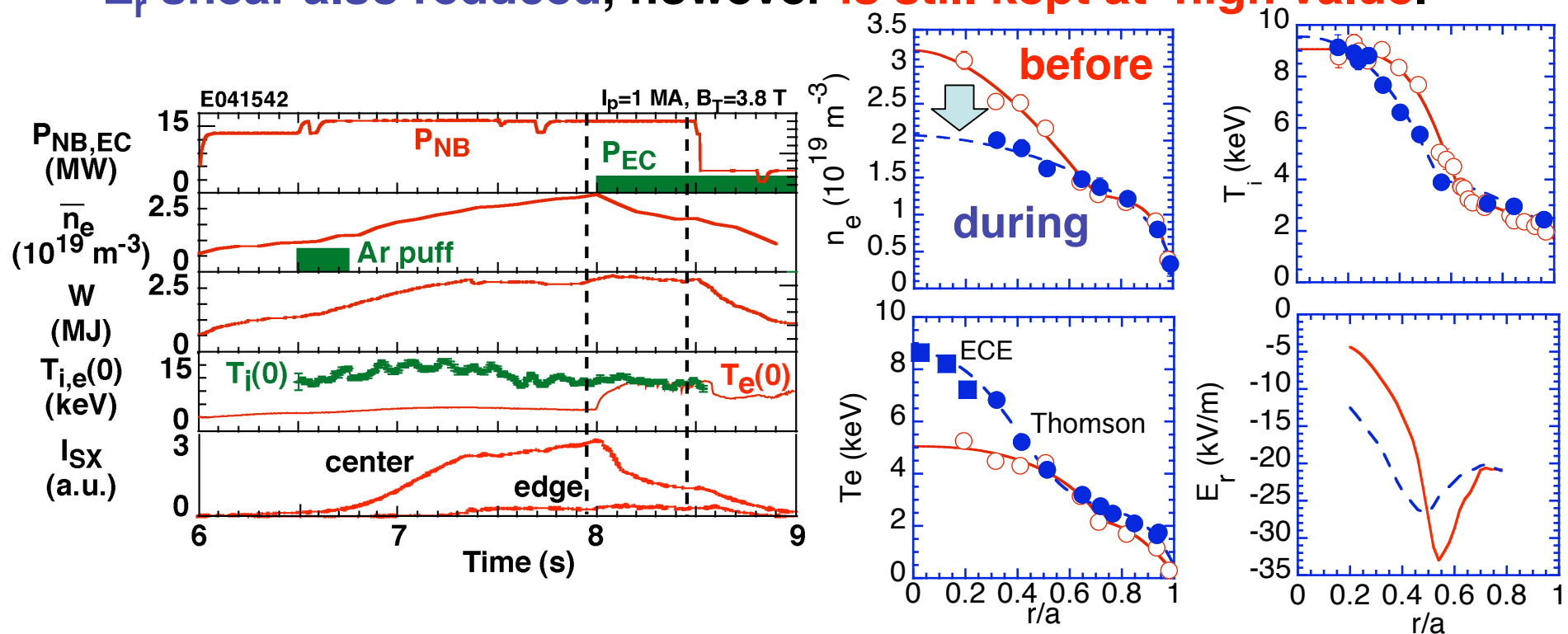


min. gradient
 $= | (dE_r/dr)_{\text{min}} |$
 max. gradient
 $= | (dE_r/dr)_{\text{max}} |$

Density profile is flattened by injecting ECRF in PS plasma with Ar puffing

JT-60U

- Large decrease of n_e is observed with small amount of Ar puffing in PS plasma.
- **Density and central soft x-ray signal are drastically reduced** by injecting ECRF.
- n_e ITB is almost lost, but T_i ITB is sustained.
- E_r shear also reduced, however **is still kept at high value.**

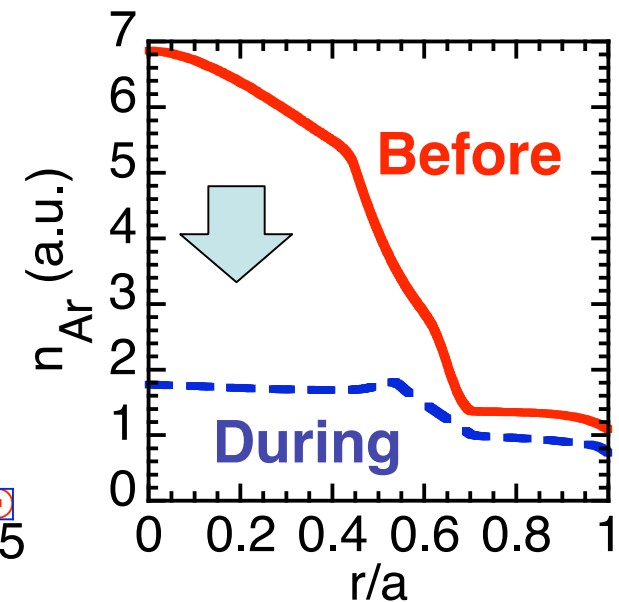
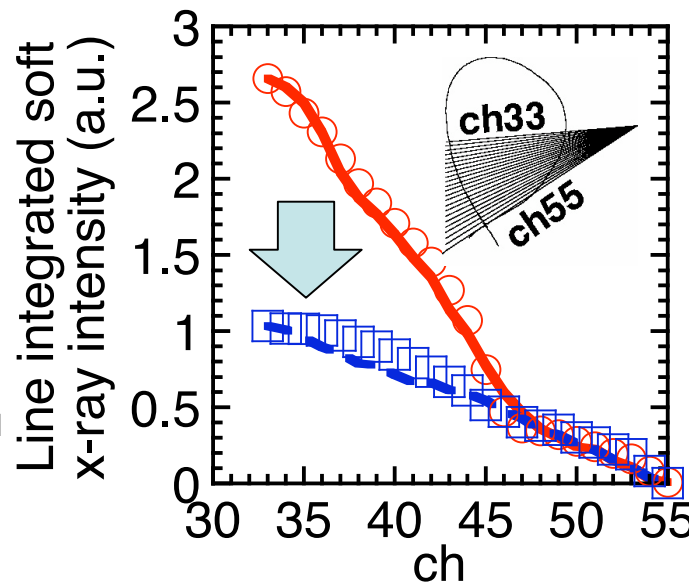
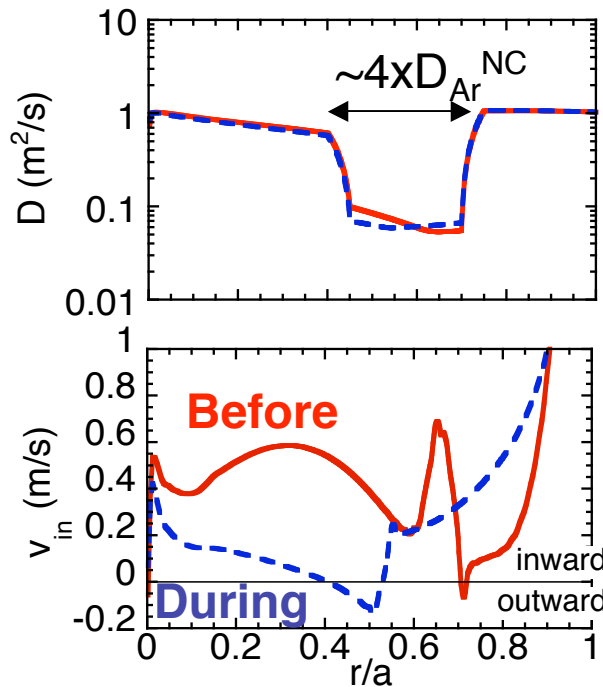


Ar is exhausted from the inside of the ITB.

JT-60U

- n_{Ar} profile estimated from soft X-ray profile is **more peaked** by a factor of **1.6** than n_e profile **before ECRF injection** and **similar** as n_e profile **during ECRF injection** in PS plasma.
- The reduction of n_{Ar} is consistent with the **reduction of v_{Ar}^{NC}** due to the reduction of n_e gradient
- D_{Ar} is higher by a factor of 4 than D_{Ar}^{NC} in the ITB region.

- Effects of Ar puffing on the flattening of the n_e profile should be investigated in a future work.



Summary

JT-60U

- ITB transport is investigated under **dominant electron heating** and **small central fueling** by using **ECRF system**.

	Reversed shear	Weak positive shear
T_e ITB formation	• Strong T_e ITB without T _i ITB (P _{EC} ~1MW)	• No strong T_e ITB without T _i ITB (P _{EC} <3MW)
Sustainment/ degradation of ITB and confinement	• Sustainment of strong ITBs (T_{i,e}, n_e) • High confinement of HH _{y2} ~2 with T _e /T _i >1	• T_i ITB degradation • Flattening of n_e profile and sustainment of T _i ITB with Ar puff
Heavy impurity accumulation	• Ar accumulation	• Ar exhaust from the inside of the ITB with flattening of n _e profile

- Further study is necessary with N-NB : Are the effects observed in PS plasma intrinsic to ECRF injection or electron heating ?

Main objectives in JT-60U 2003-4 experiment campaign

JT-60U

- Long sustainment ($\sim 30-60$ s) of high performance plasmas for $>\beta_R$ and $\sim\beta_{wall}$
 - Extension of operation pulse length (15 s \rightarrow 65 s)
 - NB power : 14 MWx30s
 - RF power : ~ 2 MWx60s
- Sustainment of high β_N (3-3.5) by stabilizing NTM
- Extension to high density towards highly integrated performance